## Form PTO-1449

## PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE CITATION

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Sheet 1 of 1

ATTORNEY DOCKET No.	SERIAL NO.
NGC-00050 (48-0032)	10/606 854
APPLICANT	
Jeffrey S. Hartlove et al.	
FILING DATE	GROUP
6/20/67	2828

OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, etc.)						
Ref. Desig.	Examiner's Initials					
1.	TN	Kooijman, G.; Brujn, R de; Koshelev, K.; Bijkerk, F.; Shaikh, W.; Bodey, A.J.; and Hirst, G.; Prepulse enhanced EUV yield from a xenon gas-jet laser produced plasma; Central Laser Facility Annual Report 2001/2002, Lasers for Science Facility Programme - Physics; pps. 142-144				
2.	TN	Berglund, M., Rymell, L. and Hertz, H.M.; Ultraviolet prepulse for enhanced x-ray emission and brightness from droplet-target laser plasmas; 1996 American Institute of Physics, Vol. 69, No. 12, September 16 1997				
3.	TN	Kodama, R., Mochizuki, T., Tanaka, K.A. and Yamanaka, C.; Enhancement of keV x-ray emission in laser-produced plasmas by a weak prepulse laser; 1987 American Institute of Physics, Vol. 50, No. 12, March 23 1987.				

Examinor. / West / Lawy Bate Solistation. / /28/03	Examiner:	Tuan	Mary	Date Considered:	1/28/05
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